

. , . . . ,

(Ni-
 SiO, Ni-Al₂O₃, Ni-ZrO₂) 30±10 , -
 - 1
 % . (-
 0,5), -
 (~10). -
 (1200) ,
 ,
 [1,2]. -
 TIRA-test 2300 -
 (12·10⁷ /) .
 290 – 600 . 0,2 %.
 () , -
 . , Ni-Al₂O₃ -
 3 – 5 , 30 %.
 , -
 « » . -
 , -
 .
 (12 18 9) -
 , -
 (– –) -
).

12 18 9 (~ 0,5 - 1),

600 .

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